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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/605,238	09/17/2003	Min-Yi Hsu	11285-US-PA	3285
31561 7	590 03/22/2005		EXAMINER	
JIANQ CHYUN INTELLECTUAL PROPERTY OFFICE 7 FLOOR-1, NO. 100 ROOSEVELT ROAD, SECTION 2 TAIPEI, 100 TAIWAN			SMITH, BRADLEY	
			ART UNIT	PAPER NUMBER
			2891	
			DATE MAILED: 03/22/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)				
Office Action Cumment	10/605,238	HSU ET AL.				
Office Action Summary	Examiner	Art Unit				
	Bradley K. Smith	2829				
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address				
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	solutions within the statutory minimum of thirty (30) days also and will expire SIX (6) MONTHS from cause the application to become ABANDONE	ely filed will be considered timely. the mailing date of this communication. (35 U.S.C. § 133).				
Status						
1) Responsive to communication(s) filed on						
2a) ☐ This action is FINAL. 2b) ☑ This	-					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	3 O.G. 213.				
Disposition of Claims						
4) Claim(s) 1-19 is/are pending in the application.						
4a) Of the above claim(s) is/are withdraw	vn from consideration.					
5) Claim(s) is/are allowed.						
6) Claim(s) <u>1-4,8,10,12,13 and 18</u> is/are rejected.						
7) Claim(s) <u>5-7,9,11,14-17 and 19</u> is/are objected						
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9) The specification is objected to by the Examiner	·					
10)⊠ The drawing(s) filed on 17 September 2003 is/a	The drawing(s) filed on <u>17 September 2003</u> is/are: a) \boxtimes accepted or b) \square objected to by the Examiner.					
Applicant may not request that any objection to the o	drawing(s) be held in abeyance. See	37 CFR 1.85(a).				
Replacement drawing sheet(s) including the correcti	- · · · · ·	• •				
11) The oath or declaration is objected to by the Example 11.	aminer. Note the attached Office	Action or form PTO-152.				
Priority under 35 U.S.C. § 119						
12)⊠ Acknowledgment is made of a claim for foreign a)⊠ All b)□ Some * c)□ None of:	priority under 35 U.S.C. § 119(a)	-(d) or (f).				
1. Certified copies of the priority documents	have been received.					
2. Certified copies of the priority documents	have been received in Application	on No				
3. Copies of the certified copies of the priori	•	d in this National Stage				
application from the International Bureau						
* See the attached detailed Office action for a list of	of the certified copies not received	d.				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary (PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da	te				
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	5) Notice of Informal Pa	atent Application (PTO-152)				

DETAILED ACTION

Specification

1. The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed.

Claim Rejections - 35 USC § 102

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 3. Claims 1-3 are rejected under 35 U.S.C. 102(b) as being anticipated by Yang et al. (US Patent 5,827,437). Yang et al. disclose the method comprising: performing a dry etching process for removing the antireflective layer (108), removing the conductive layer (106), and removing the barrier layer (104) (columns 1-3 and figures 1a and 1b). With regards to claim 2, Yang et al. disclose the anti-reflective layer being made of TiN and being etched with Cl₂ (see columns 1-3). With respect to claim 3, Yang et al. disclose the use of CHF₃ (see column 9 lines 25-35).

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- 5. Claims 4, and 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yang et al. (US Patent 5,827,437) in view of Chen et al. (US Patent 6,753,249). Yang et al. disclose the method comprising: performing a dry etching process for removing the antireflective layer (108), removing the conductive layer (106), and removing the barrier layer (104) (columns 1-3 and figures 1a and 1b). However Yang et al. fail to disclose the wet etch in order to remove the conductive layer. Where as Chen et al. disclose the removal of the conductive layer by wet etching (column 5 lines 18-30). Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to combine the teachings of Yang et al. and Chen et al. because wet etching will isotropically etch the conductive layer.
- 6. Claims 4, 8, 10, 12, 13, and 18 are rejected under 35 U.S.C. 103(a) as being unpatentable over Yang et al. (US Patent 5,827,437) in view of Chen et al. (US Patent 6,753,249). Yang et al. disclose the method comprising: performing a dry etching process for removing the antireflective layer (108), removing the conductive layer (106), and removing the barrier layer (104) (columns 1-3 and figures 1a and 1b). However Yang et al. fail to disclose the chemical mechanical polishing (CMP) step in order to remove the barrier layer (with respect to claim 8, and the wet etching step of the conductive layer). Where as Chen et al. disclose the removal of the barrier layer by CMP (and the wet etching step) (see column 5 lines 30-45). Therefore it would have been obvious to one of ordinary skill in the art at the time the invention was made to combine the teachings of Yang et al. and Chen et al. because with CMP one can

precise detect the when the barrier layer has been removed and with a wet one can etch the conductive layer isotropically.

Allowable Subject Matter

- 7. Claims 5-7, 9, 11, 14-17, 19 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.
- 8. The following is a statement of reasons for the indication of allowable subject matter: the prior art of record neither teaches nor suggests the wet etching the conductive layer with sulfuric acid (claims 5, 6, 15, 16) etching the conductive layer with nitric acid (claims 7, and 17) the slurry containing aluminum oxide and hydrogen peroxide (claims 9, 11, 14, and 19).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Bradley K. Smith whose telephone number is (571) 272-1884. The examiner can normally be reached on 10-6 Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Bill Baumeister can be reached on (571) 272-1722. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Brad Smith

Primary Examiner

. Art Unit 2829